

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Sung Chul Kang, et al.)	
)	Group Art Unit: 1752
Serial No.:	10/750,845)	
)	
Filed:	January 5, 2004)	
)	Examiner: Chu, John S. Y.
For:	PHOTORESIST COMPOSITION FOR)	
	MULTI-MICRO NOZZLE HEAD COATER)	

AMENDMENT AND RESPONSE

VIA EFS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment and Response is in response to the Office Action dated April 17, 2007. Please amend the application as follows: